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Factors Influencing the Performances of Micro-Strips Gas Chambers

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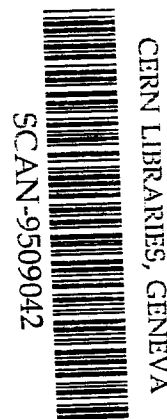
Abstract

Damages to MSGCs induced by discharges have been investigated. Optimization of electrode shapes and/or deposition of a protective coating allows to increase the potential difference between anode and cathode, thus increasing the gain.

For prototypes of MSGCs made at the Centre de Recherches Nucléaires, each step of the manufacturing processes was carefully controlled. Results are presented on the influence of cleaning processes on the surface resistance of glass substrates.

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1 Introduction

The microstrips gas chambers (MSGC) introduced by Oed [1] operate like conventional multiwire proportionnal chambers (MWPC). Electrode strips etched by photolithography on a substrate replace wires, and pitch between anode and cathode is an order of magnitude smaller for MWPCs. The drift region is shaped by a cathode plane placed at a few millimeters from the substrate. Primary electrons are multiplied in the amplification region close to anode strips.

The gain of gaseous counters is a function of at least three parameters : detector geometry, gas mixture and voltages.

For MWPCs the gain depends on the wire radius. In a similar way, the gain of MSGCs depends on anode and cathode widths. Several studies [2, 3] show that one can increase the gain by reducing the width of anodes to 10 or 5 μm , and by increasing the width of cathodes to 100 or 150 μm .

The gain dependance on cathode voltage for various mixtures of argon and dimethylether (DME) was studied. The maximum gain before breakdown is typically in the order of $3 \cdot 10^3$ to $5 \cdot 10^3$.

2 Breakdowns of MSGCs

There are essentially two sources of damage in wire chambers. The first is formation, in electronic avalanches, of polymeric compounds that produce a deposit on wires. This may effect a loss of gain, depending on the gas mixture [4]. This problem exists also for MSGCs [5]. To prevent it a "clean" gas mixing system has to be used, and all possible polluting agents have to be eliminated. DME-based mixtures are favored over hydrocarbons [6].

A second source of damage is breakdown between electrodes. In MSGCs, a spark between anode and cathode may lead to an evaporation of metal, this eroding and cutting one or more of the strips [7].

To increase the maximum stable gain before discharge, two solutions, maybe complementary, are presented : optimization of electrode design and protection of points where sparks occur.

Three lay-outs of electrodes have been studied sofar (see fig.1). An electrostatic simulation programme ("COSMOS") was used to calculate the field at the ends of cathodes and anodes for the following conditions. Cathode width: 70 μm , anode width: 9 μm , pitch: 200 μm , drift voltage: -1200 V on a 3 mm gap, cathode voltage: -420 V, anode voltage: 0 V and glass substrate was assumed for the simulation. The points of maximum field strengths are indicated in fig.1 by arrows. The electrostatic simulation was made in two dimensions. The thickness strip effect was neglected and maximum field values are underestimated. However this calculation allows comparisons.

To localise discharges visually, a MSGC with semitransparent window was used. Measurements are performed with an Ar-DME (90-10) mixture and a drift voltage of -1200 V. Cathode strip voltages were increased until sparking

was observed. It was found that sparking starts first at the end of cathodes (fig.2) whereas electrostatic simulation predicts sparking to begin at the ends of anodes. Discharge at the end of cathodes occurs, on the other hand, at the field values predicted by electrostatic simulations. One is lead to conclude that electrostatic simulations are not sufficient to correctly predict MSGC performance. It may therefore be necessary to consider electrodynamic processes [8].

The measurements show (tab.1) that designs n° 1 and 2 (longer cathodes) support high voltages before breakdown. An increase cathode voltages of 30 V improves the gas gain by up to a factor 2. The region where sparks were detected was then covered by a dielectric glue (Epotecny 505) and the procedure was iterated. For the three designs, protection of the end of cathodes allows to increase cathode voltages to 490 V. And then sparking starts at defective points along the strips. For design n°0, this points were covered by glue and the procedure was iterated (tab.2). Protection allows to increase cathode voltages by up to 80 V, compared to the initial value 450 V, corresponding to an increase of gain by a factor 4.5.

Breakdown is a particulrly serious problem on the cathode ends side. To prevent discharges, we found that electrode design n° 1 is better and passivation of critical regions, with protective coating is more effective.

3 Influence of cleaning processes on surface resistance of glass

Before etching four different cleaning solutions have been tested. These included chemicals which are ordinarily used during the different phases of lithography. Ultrasonic bath was also always applied in the cleaning process.

The mildest chemicals used for cleaning are distilled water and solvents like alcohols and acetone. These do not have any effects on glasses. One solution was Merck's Extran^R which is a commercial cleaning agent for glasses and optical instruments. It contains alkalines like sodium hydroxide. Another cleaning liquid is pure sulphochrome (sulphuric acid + potassium dichromate) or sulphochrome plus hydrofluoric acid. The adhesion of strips is usually better with stronger chemicals as they attack the surface of glasses and remove inorganic impurities.

The surface resistance of the two glasses, Schott D263 and Corning 7059, was measured as function of cleaning treatment. A current was measured between two probes 5 mm apart from each other for a voltage of 200 V. The resistances obtained are shown in table 3, they vary by up to three orders of magnitude.

Water plus solvent cleaning gave the nominal surface resistances of Schott D263 and Corning 7059 glasses which were $2.8 \cdot 10^{14}$ and $10^{15} \Omega$ respectively, according to the manufacturer. On the contrary, additional cleaning agents had clear effects on the resistances of the substrates.

The change caused by Merck's Extran^R is understood as due to diffusion of

sodium ions into the Schott D263 glass. Sodium ions can not diffuse into the Corning 7059 glass according to the manufacturer, and so no modification of resistance has been observed. Clearly, diffusion of sodium ions into the Schott D263 glass is enhanced when heating the substrate.

The modification due to sulphochrome were probably caused by ion diffusion into glass. It is known that chromium ions diffuse in silicate substrates, as observed for silicon [9]. Diffusion of such multivalent ions reduce the surface resistivity of the substrate.

Hydrofluoric acid used after sulphochrome, etches glass and then removes part of the previously diffused chromium ions. This leads to the observed increase of the surface resistivity; it is more important for the Corning 7059 glass than for the Schott D263 glass. According to the manufacturer, Corning 7059 glass has to be cleaned without any acid solution that may damage the surface.

4 Conclusion

Some factors influencing counter performances are comparable for MWPC and MSGC : such as of polymerization in gas, and detector geometry. On the other hand, the problem of breakdown is more important for MSGCs. Optimization of electrode shapes and deposition of protective coating allows to increase the maximum field for stable gain.

For MSGC, surface resistance seems to be the most essential problem. It has been shown previously that surface resistance evolution leads to dramatic changes of gain, especially under irradiation.

It has been shown here that surface resistance can vary up to 3 orders of magnitude due to the chemicals used in the cleaning process before metalisation. Studies are now under way at CRN-Strasbourg to understand effects of the etching process. One concludes from these investigations that all operations related to the fabrication of MSGCs have to be carefully controlled in order to ensure a viable solution for a MSGC-based tracking device for LHC experiments.

References

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Design n°	0	1	2
Cathode voltages first sparks	-455 ±5 V	-485 ±5 V	-475 ±5 V
Gas Gain	1700	3300	2700

Tab.1 : Limit of cathode voltages before sparks and corresponding gain.

	Cathode Voltages First Spark	Localisation of Discharges
no protection	-450 ±5 V	end of cathodes
protection of : ends of cathodes	-480 ±5 V	defective points along the strips
protection of : ends of cathodes + defective points along strips	-530 ±10 V	ends of anodes
protection of : ends of cathodes + defective points + ends of anodes	-530 ±10 V	

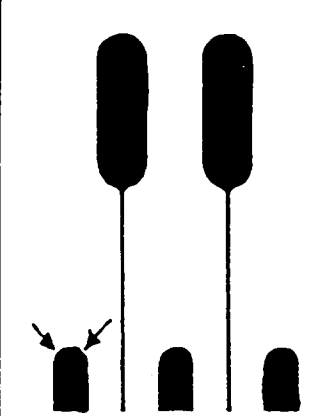
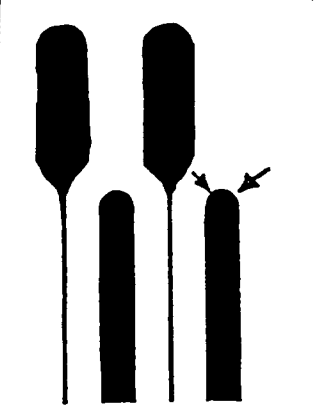
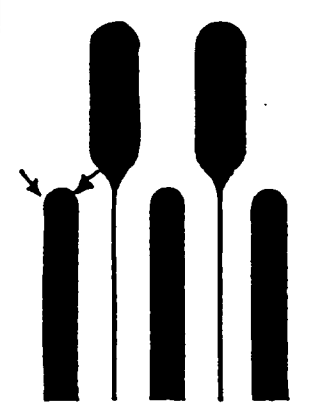
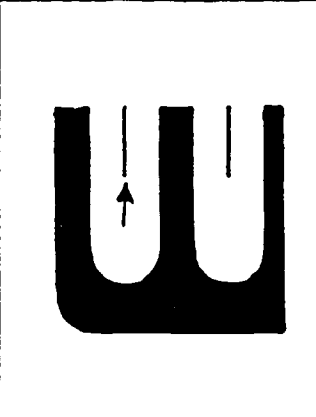
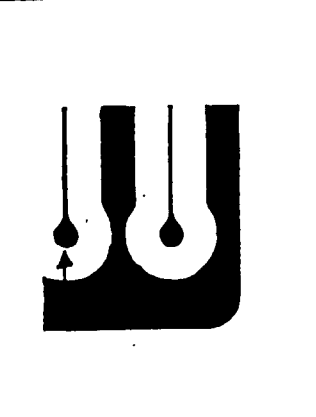
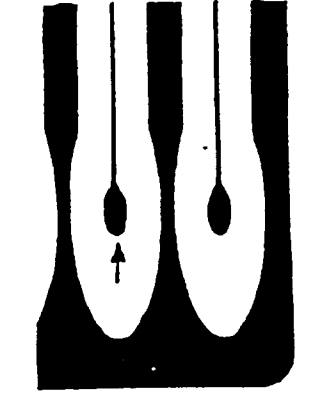
Tab.2 : Localisation of breakdowns in MSGC (design n°0) and effect of coating in the region where discharges occur.

Cleaning	Schott D263	Corning 7059
water and solvent	2.8 10 ¹⁴	10 ¹⁵
Merck's Extran ^R	3.7 10 ¹²	10 ¹⁵
Merck's Extran ^R Baked at 400°C N ₂	1.2 10 ¹²	-
Sulphochrome*	2.6 10 ¹³	9 10 ¹¹
Sulphochrome* + hydrofluoric acid (10%)	2.9 10 ¹³	3.1 10 ¹³

Tab.3 : Surface resistance R in ohm of D263 and 7059 glasses for different cleaning solutions.

Merck's Extran^R : alkaline mixture

*mixture of potassium bichromate (K₂Cr₂O₇) and sulphuric acid (H₂SO₄)

Design n°	0	1	2
Maximum field	105 kV/cm	110 kV/cm	110 kV/cm
Ends of cathodes			
Ends of anodes			
Maximum field	250 kV/cm	130 kV/cm	123 kV/cm

→ : localisation of maximum field

Figure 1: Designs of electrodes, localisation and values of maximum field (COSMOS simulation) at the ends of cathodes and anodes.

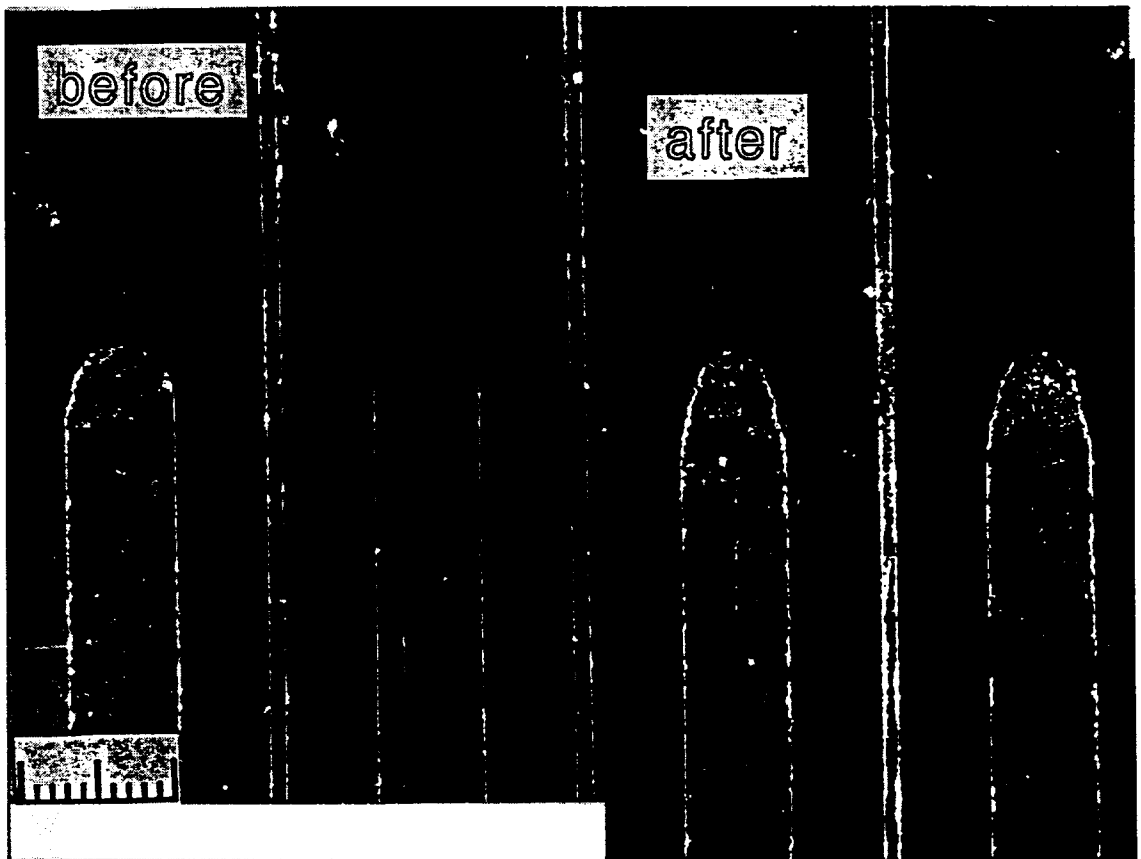


Figure 2: Ends of cathodes before and after discharge (scale = 100 μm).

